



Docket 80236A/PCW
Customer No. 01333

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of

Ramanathan Srinivasan, et al

SLURRY FOR CHEMICAL
MECHANICAL POLISHING
SILICON DIOXIDE

Patent No. 6,491,843 B1

Issued 12-10-2002

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

REQUEST FOR CERTIFICATE OF CORRECTION
UNDER RULE 322

Request is hereby made on behalf of the inventor and assignee that hereinafter-identified mistakes in the above-identified patent can be corrected by issuance of a Certificate of Correction. Such mistakes occurred in some instances as a result of the fault of the Patent Office.

The location of such mistakes in the patent, and of the corresponding correct language in the application, are as follows:

Patent Reference

Column 12, claim 1, line 21
Column 12, claim 7, line 44

Application Reference

Page 19, claim 1
Page 19, claim 7

The Director is hereby authorized to charge any fees in connection with this communication to Eastman Kodak Company Deposit Account No. 05-0225.

A duplicate copy of this letter is enclosed.

Respectfully submitted,

Attorney for Patentee(s)
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JUN 02 2004

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE
CERTIFICATE OF CORRECTION

PATENT NO.: 6,491,843 B1

DATED: 12-10-2002

INVENTOR(S): Ramanathan Srinivasan, et al

It is certified that an error appears in the above-identified patent and that said Letters Patent is hereby corrected as shown below:

Column 12, claim 1, line 21	Please replace the word "silicone" with the word --silicon--
Column 12, claim 7, line 44	Please replace "HN ₃ " with --HNO ₃ --

UNITED STATES PATENT AND TRADEMARK OFFICE
CERTIFICATE OF CORRECTION

PATENT NO. : 6,491,843 B1
DATED : December 10, 2002
INVENTOR(S) : Ramanathan Srinivasan et al

Page 1 of 1

It is certified that error appears in the above-identified patent and that said Letters Patent is hereby corrected as shown below:

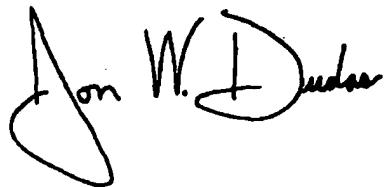
Column 12.

Line 21, please replace the word "silicone" with the word -- silicon --

Line 44, please replace "HN₃" with -- HNO₃ --

Signed and Sealed this

Thirteenth Day of July, 2004



JON W. DUDAS
Acting Director of the United States Patent and Trademark Office